

ELECTRONIC STRUCTURE AND MAGNETIC PROPERTIES OF TiMn₃N, TiMn₃ AND MnTi₃ COMPOUNDS USING TB-LMTO METHOD

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Abstract

Tight Binding Linear Muffin Tin Orbital Method has been employed to obtain the electronic and Magnetic properties of TiMn₃N and ordered TiMn₃ Compounds. The Equilibrium volume has been found for each compound using self-consistent band structure calculations at several lattice parameters. Obtained results reveals that TiMn₃ is ferromagnetic with 3.3624μB as magnetic moment at Mn sites and -1.2174μB at Ti sites. Hence TiMn₃ attains the stable magnetic order at Ferromagnetic and Non-Magnetic calculations, while TiMn₃N shows the nonmagnetic phase as a stable one during FM and NM calculations.

Keywords: Ferromagnetic, Non-Magnetic, Tight Binding Linear Muffin Tin Orbital method

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1. INTRODUCTION

Titanium based Nitrides are of great importance because of its tremendous industrial applications such as Lithium-ion batteries, energy storage, fuel cells and biomedical industries. Various Experimental and Theoretical works has been done in Titanium nitrides that provides ultra-hardness, corrosion resistance and mechanical resistance. Analyzing the magnetic properties of these nitrides offers high wear resistant property to the materials. [1-16]. Some Titanium nitrides are considered as high technology materials often used in microelectronics, space technology, Aero planes industry and biomaterials, due to their exceptional physical and chemical properties [17-19]. These type of compounds are chemically stable and shows good corrosion resistance even at room temperature and they are used as biocompatible layers for orthopedic and dental implants. Finally, their hardness is among the highest next to diamond. It has contributed to the industrial use of titanium nitrides, as good candidates for applications needing high wear resistance [20, 21]. On the other hand, titanium nitrides are widely used in semi-conductors technology as dilution barriers [22, 23]. Titanium nitrides doped with transition metal atom displays a wide range of interesting phenomenon of converting the semiconducting materials to magnetic and superconducting compounds [24]. Also it has got excellent electrical and thermal conductivity, high chemical and thermal stability and good wear and corrosion resistance. All these properties make them suitable for many technological applications. Titanium nitride is also used as an electrically conducting barrier. Thus these compounds have great scientific and technological interest [25]. The investigated structural properties of the XFe₃N cubic ternary iron based nitrides reveals that in the cases of ScFe₃N, CoFe₃N,

NiFe₃N, CuFe₃N and ZnFe₃N, the equilibrium configurations corresponds to the Pm-3m structure [27]. Substitution of Zn for Fe in γ'-Fe₄N improves the corrosion resistance as well as mechanical properties [26]. The electronic structure of compounds FeV₃, VFe₃, V₄N, VFe₃N, and FeV₃N, has been studied using the LMTO method. With the use of total energy calculations the equilibrium lattice parameters for these compounds are calculated. Since the V₄N, FeV₃N and VFe₃N nitrides shows nonmagnetic, the substitution of iron by vanadium atoms destroys the ferromagnetic order of the-Fe₄N nitride [28]. Magnetic and electronic properties of the two compounds γ'-AgFe₃N and γ'-AuFe₃N has been studied using LMTO calculations and correlated with experimental results [29]. Similarly, LMTO method are engaged to investigate the electronic structure and local magnetic properties of the ferromagnetic iron nitrides RuFe₃N, ZnFe₃N, InFe₃N, Fe₃BN, PdFe₃N, MnFe₃N and SnFe₃N[30-35].

Considering all the above references, γ'-Fe₄N has been used as model compound substituting the transition metal atoms in place of Fe atom and the electronic and various other properties of these compounds has been studied using LMTO methods of calculation. In the present work, three Fe atoms are replaced by Ti atom and one Fe atom by other transition metal atom Mn to analyze the magnetic properties of those compounds with and without nitrogen.

2. METHODS OF CALCULATION

Basic research in the material science includes the study of electronic structure as the beginning for all the physical properties. Band structure calculations have proved to be tremendously useful in relating the vital feature of all band

calculations with the large experimental data. Band structure calculations may be referred as linear method, introduced by O. k. Anderson in 1971, which are later derived as many efficient computational patterns. One of these linear methods that solves self-consistent electronic structure problem in an extremely effective way is the Linear Muffin Tin Orbital (LMTO) method. Using this method various calculations for infinite crystals and ground state properties of real materials may be estimated [36]. The simplest and most widely used one-electron Hamiltonian is tight-binding (TB) method with minimal base and in its two-Centre approximation has been necessary for self-consistent density-functional calculations. The transformation of muffin-tin orbitals into a TB item frequently and successfully used in first principle band structure calculations. The transformation made by LMTO method is exact for all results obtained. By using this method or with the almost identical augmented spherical wave method, the results can always be reproduced by the TB method. The TB-LMTO's have an almost universal decay with the so-called atomic sphere approximation [37, 38].

The electronic structure and ground state properties of $TiMn_3N$, $TiMn_3$ and $MnTi_3$ compounds have been studied by using self-consistent TB-LMTO method. These compounds crystallize the simple cubic structure with space group Pm-3m (space group no: 221). In order to find the phase stability of the compounds, the total energies has been calculated for these compounds and fitted with Birch Murnaghan equation of state [39-40]. The ferromagnetic and nonmagnetic calculations has also been performed to investigate the magnetic behavior of the compounds.

It is assumed that the crystal structures of titanium based manganese nitride and titanium nitride as simple cubic, in which the metal atoms occupy the corner sites and the face centered position, while nitrogen atoms occupy the body-centered sites. A spin-polarized LMTO calculation has been performed using the Von Barth and Hedin Parameterization [41] for exchange–correlation energy of the electron gas.

Progressing LMTO calculations has been made without spin–orbit interaction but including the mass correction terms. For $TiMn_3N$ nitrides the Wigner–Seitz Spheres (Si) around Titanium and Manganese atoms has been taken to be of equal size. The one-electron potentials has been self-consistently obtained using reciprocal space sums with 216 k-points having 20 irreducible k points within the entire part of the Brillouin zone. The self-consistent iterations has been carried out until energy convergence on a scale better than 0.1 mRy. Solutions for the Schrodinger equations has been used s, p, d, f basis functions for metals (Mn, Ti) and s, p, d basis functions for nitrogen. The densities of states (DOS) has been calculated as a sum of delta functions for 6 x 6 x 6 mesh points. In the present study, 3d and 4s orbital's of Ti, 3d and 4s orbital's of Mn and 2s and 2p orbitals of N has been treated as valence states.

3. RESULTS AND DISCUSSION

The Total energy calculation has been performed for compounds without nitrogen, namely, $TiMn_3$ and $MnTi_3$. The calculated binding curves between total energies in Rydberg and lattice parameters in atomic units of those two compounds have been shown in Fig 1.

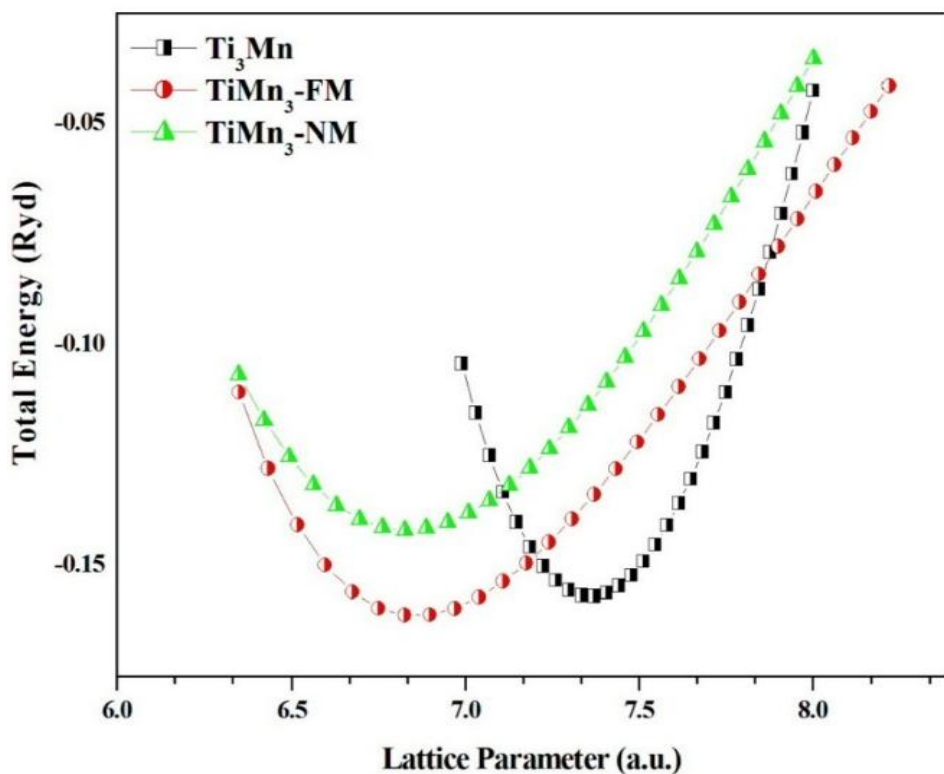


Fig.1. Binding curves between total energies (in Rydberg) versus lattice spacing 'a' (atomic units) for the compounds $TiMn_3$ (NM & FM) and $MnTi_3$.

Table.1. Estimated lattice parameters and Bulk moduli for the compounds Ti_4N , $TiMn_3N$, $TiMn_3$ -FM, $TiMn_3$ -NM and $MnTi_3$

	Ti_4N	$TiMn_3N$	$TiMn_3$ (FM)	$TiMn_3$ (NM)	$MnTi_3$
A (a.u)	7.8265	7.2139	7.8729	6.8299	7.3585
B (GPa)	192.27	388.28	249.85	247.47	154.78

A drastic change in the lattice spacing has been observed from $MnTi_3$ to $TiMn_3N$ while including Nitrogen as shown in Table.1. Titanium is at face-centered positions for $MnTi_3$ and a ferromagnetic calculation gives null local magnetic moments at Mn and Ti sites. It denotes that the stable phase of $MnTi_3$ is nonmagnetic, has been evidenced by analyzing the occupation numbers for this compound. Also it shows a charge transfer from Ti atoms to Mn atoms that populate the spin-down d-states giving an equal occupation numbers for both spin directions. Figure.1. shows that $TiMn_3$ attains two binding curves through nonmagnetic (NM) and ferromagnetic (FM) calculations. Regarding the analysis of the occupation numbers, Mn atoms receives the net magnetic moment from spin-down d-electrons that has been partially unoccupied whereas Ti atoms occupies spin-up d-states, that results in the opposite local magnetic moments at Fe and Ti sites at theoretical equilibrium volume. The magnetic moment vanishes for lower volumes (at high pressure) as shown in fig.2.

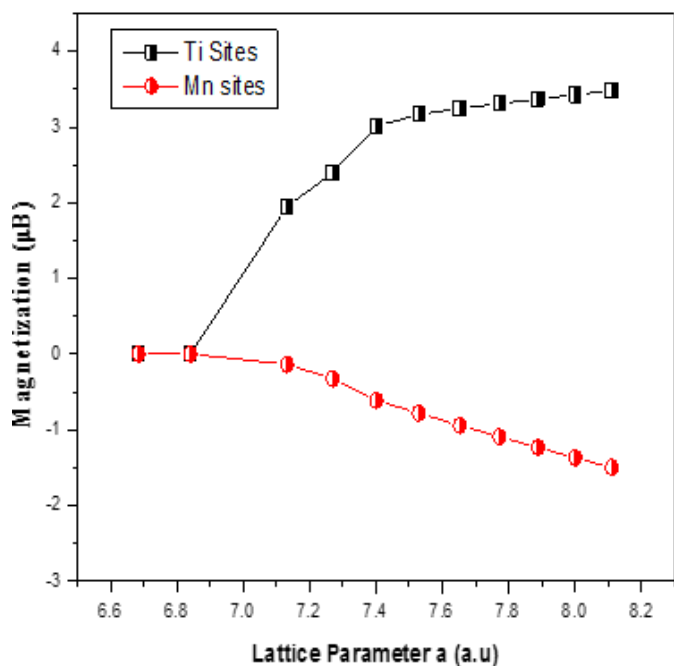


Fig.2 Magnetization (in Bohr Magnetons) versus Lattice Parameter (in atomic units) for $TiMn_3$

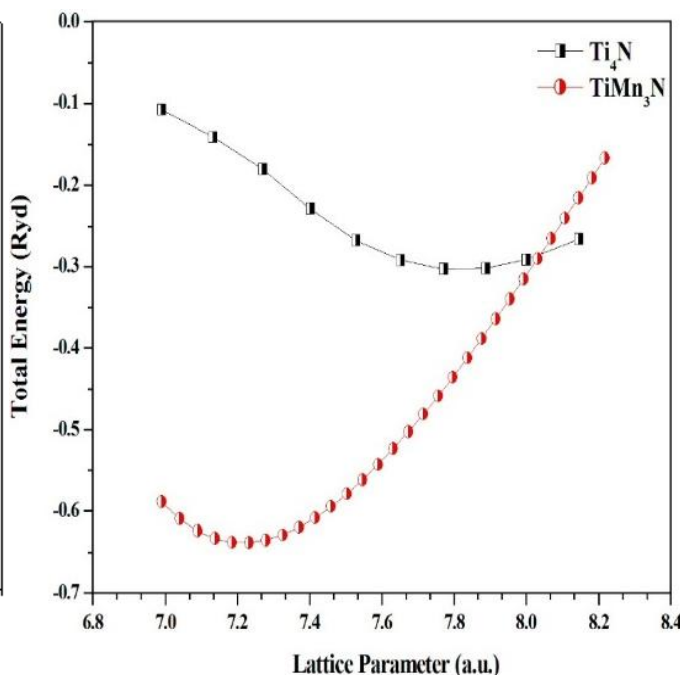


Fig.3 Total Energy (in Rydberg) versus Lattice parameter (in atomic units) for Ti_4N and $TiMn_3N$

The above two branches NM and FM states in figure.2. overlaps at a junction, where moment can be zero without any change in total energy of the system presents the first order magnetic shift. Figure.3. provides the binding curves for Ti_4N and $TiMn_3N$ attained through Birch- Murnaghan fitting and the equilibrium lattice parameters found are given in table.1. The electronic distribution and charge transfer of titanium, manganese and nitrogen atoms are calculated using ferromagnetic calculations and given in Table.2.

Table.2. Number of electrons in each state per spin, charge transfer at each site and Fermi energy.

$TiMn_3N$	Ti			Mn			N		
	Spin up	Spin down	Difference	Spin up	Spin down	Difference	Spin up	Spin down	Difference
n_s (electrons/spin)	0.53189	0.53189	0.0000	0.17025	0.17025	0.0000	0.77676	0.77676	0.0000
n_p (electrons/spin)	0.95395	0.95395	0.0000	0.22639	0.22639	0.0000	1.77238	1.77238	0.0000
n_d (electrons/spin)	1.90301	1.90301	0.0000	2.60236	2.60236	0.0000	0.06498	0.06498	0.0000
ΔQ (electrons)	-1.28325			0.00177			-2.33075		
E_F (Rydberg)	-0.121893								

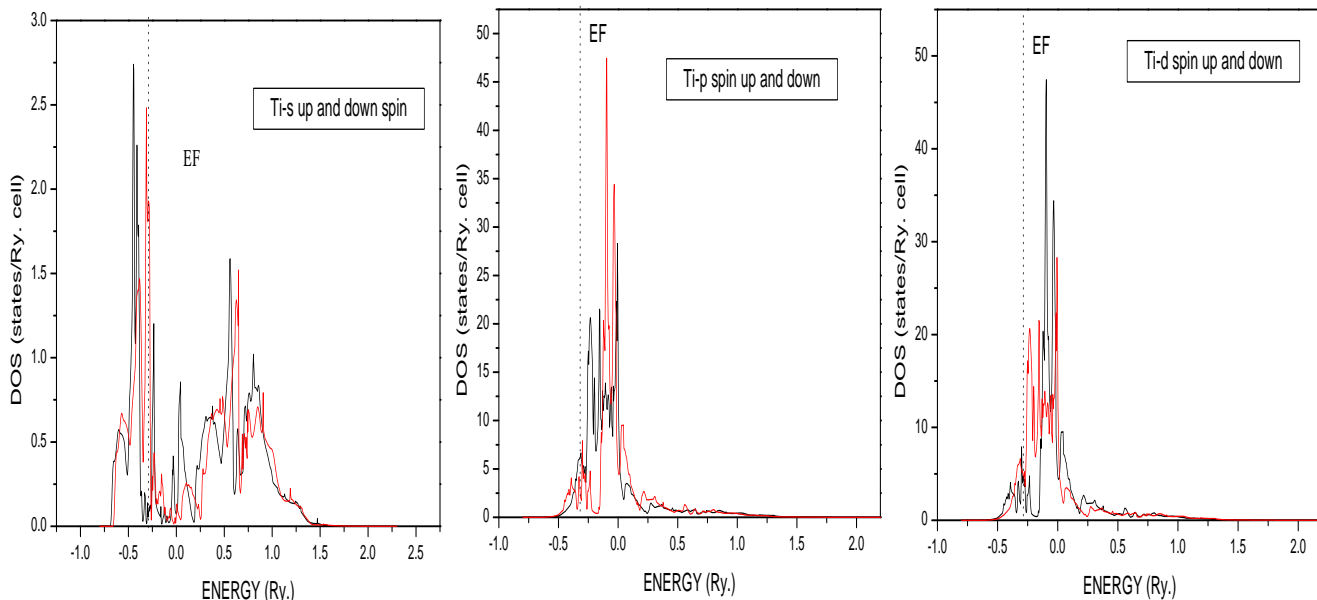


Fig.4 The s, p and d projected densities of states for spin up and spin down electrons at Ti sites for $TiMn_3$.

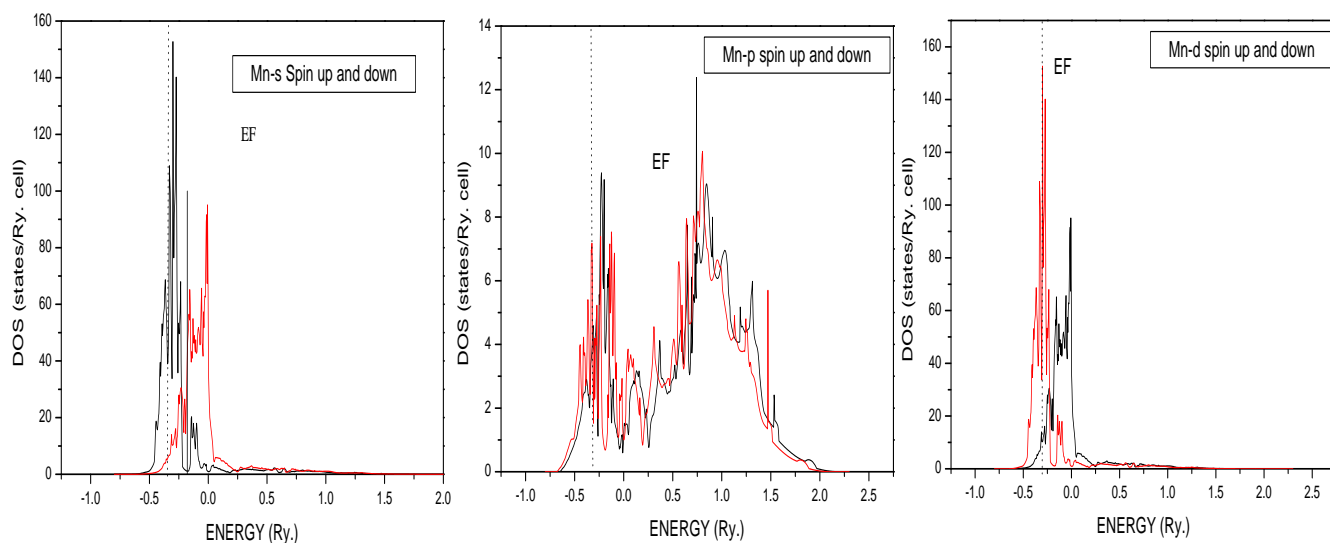


Fig.5 The s, p and d projected densities of states for spin up and spin down electrons at Mn sites for $TiMn_3$.

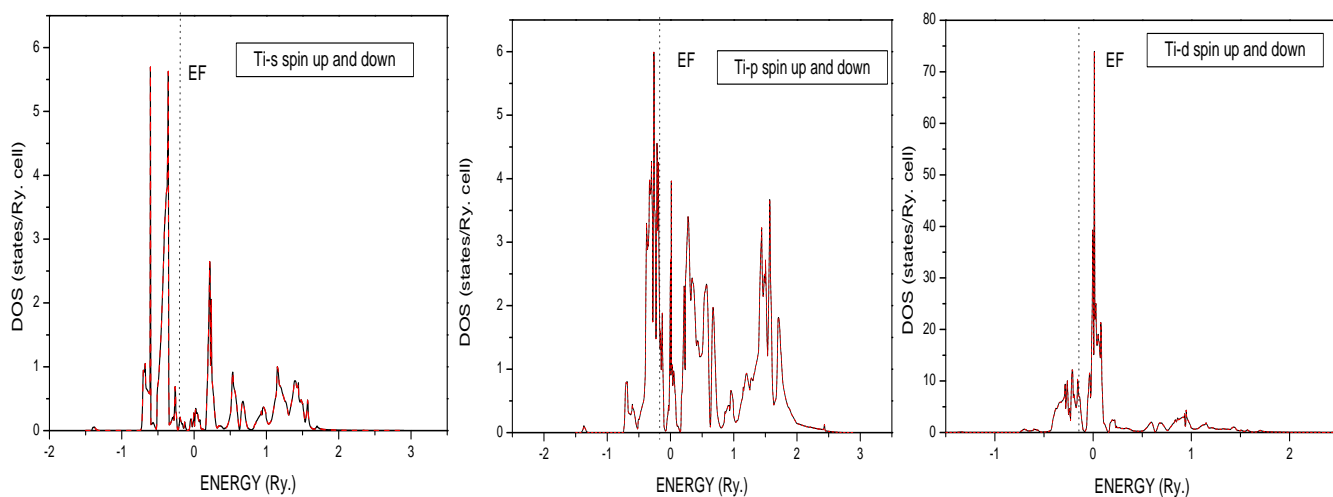


Fig.6 The s, p and d projected densities of states for spin up and spin down electrons at Ti sites for $TiMn_3N$.

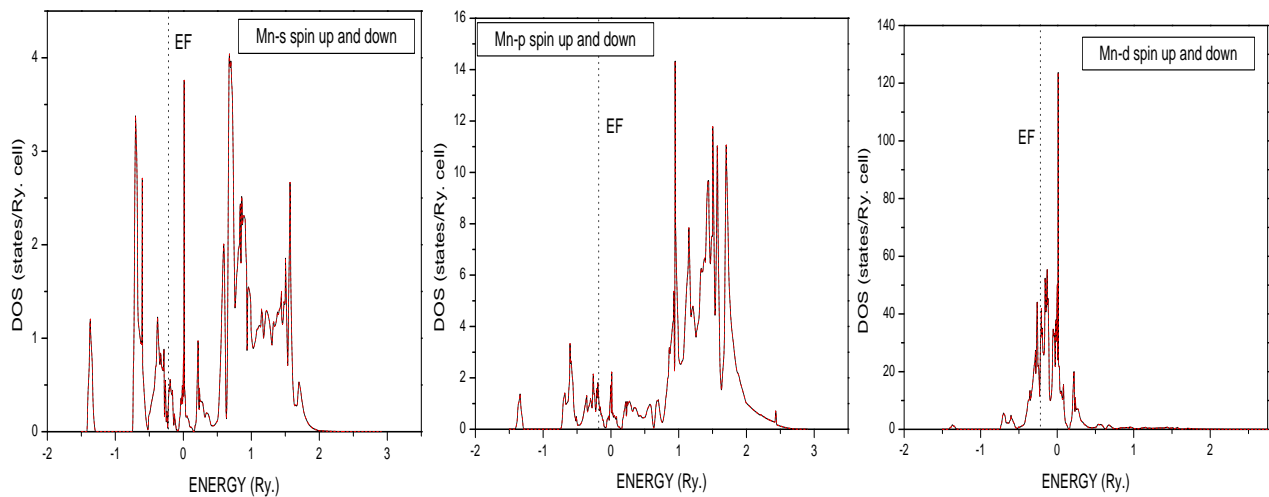


Fig.7 The s, p and d projected densities of states for spin up and spin down electrons at Mn sites for TiMn_3N .

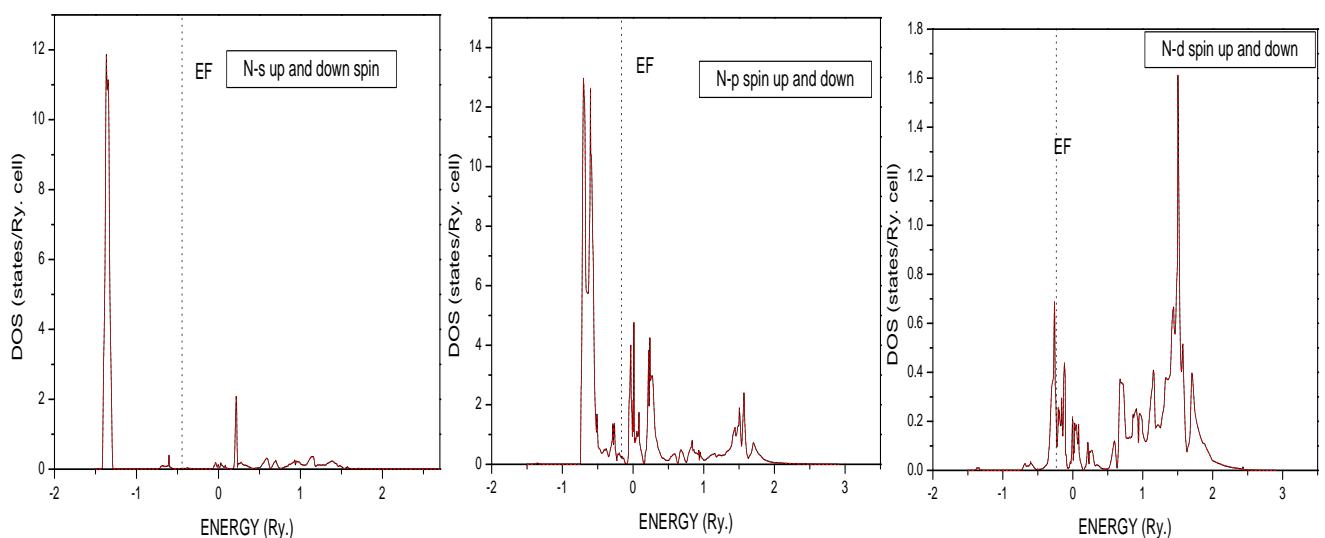


Fig.8 The s, p and d projected densities of states for spin up and spin down electrons at N sites for TiMn_3N .

The l -projected densities of states (l -DOS) at the theoretical equilibrium volume for both compounds has been investigated to get clear knowledge about the trends of the chemical bonds. Figure 4-8 shows the calculated s,p and d densities of states for both spin directions at Ti and Mn sites for TiMn_3 and Ti, Mn and N sites for TiMn_3N . The potentials obtained for spin up and spin down electrons remains same (in the case of TiMn_3N) will be easily understood for nonmagnetic electronic behavior. Contrarily, ferromagnetic compounds (in the case of TiMn_3) exhibits the different DOS for up and down spin populated by the unoccupied spin down d-states provides a net local magnetic moment at these sites as shown in figure. 4-5. Hence the increase in bulk moduli according to these interactions of TiMn_3N has the higher bulk modulus (table.1.) than others which are reflected in DOS at various sites that has been analyzed clearly. Hence these changes in the densities of states profiles of TiMn_3N and TiMn_3 is due to changes in the self – consistent potentials felt by the electrons after interfering nitrogen.

4. CONCLUSION

The electronic structure, ground state properties and magnetic behavior of compounds TiMn_3N , TiMn_3 and MnTi_3 are well known due to their excellent applications has been analyzed using TB-LMTO method. The total energy calculations have been engaged to determine the stable crystallographic parameters. The ferromagnetic calculations gives a null local magnetic moments for MnTi_3 at Mn and Ti sites which indicates that the stable phase of MnTi_3 is nonmagnetic as a result of charge transfer from titanium atom to Manganese atom giving an equal occupation numbers for both spin up and spin down directions and are verified by projected DOS profiles. Concerning TiMn_3 , the value of magnetic moments after the analysis of Ferromagnetic calculations are $-1.2174\mu\text{B}$ at Titanium sites and $3.3624\mu\text{B}$ at Manganese sites and the total magnetic moment per unit cell $8.8698\mu\text{B}$. The magnetic moments has been calculated for both sites for TiMn_3 as a function of lattice parameter shows that, for larger volume there exists a ferromagnetic order but the null magnetic moment exists with a small decrease in the lattice constant nearly $a = 6.82$ a.u. destroying the ferromagnetic order. On the subject of

TiMn₃N nitride, ferromagnetic calculations gives null magnetic moments at all sites and provides the ground state of this nitride is nonmagnetic. Hence it is concluded that inclusion of nitrogen with TiMn₃ destroys the ferromagnetic order due to the charge transfer from Ti and N to Mn atom, provides different spin and these densities of states has also been analyzed for TiMn₃ compound.

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